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In the Claims:

- 1. (Currently Amended) An implantable electrode <u>intended</u> to be directly contacted by body fluids or imbedded in body <u>tissue</u>, which comprises:
 - a) a substrate;
 - b) a biocompatible and electrically conductive catalyzing coating supported on the substrate; and
 - c) a multiplicity of carbon-containing nanotubes

 comprising a length between first and second
 ends, wherein a substantial number of the
 nanotubes are adhered adhering to the coating at
 only their first end, and wherein if there are
 nanotubes adhered to the substrate at both their
 first and second ends, the first and second ends
 are of the same polarity.
- 2. (Original) The electrode of claim 1 wherein the substrate is selected from the group consisting of tantalum, titanium, zirconium, iridium, platinum, and niobium.
- 3. (Currently Amended) The electrode of claim 1 wherein the <u>substrate</u> is different than the <u>catalyzing</u> coating and <u>the catalyzing</u> coating is selected from the group consisting of tantalum, titanium, zirconium, iridium, platinum, niobium, carbon, and nitrogen-doped carbon.
- 4. (Original) The electrode of claim 3 wherein the nitrogen in the nitrogen-doped carbon is provided at a concentration of about 1 to about 57 atomic percent.

- 5. (Original) The electrode of claim 1 wherein the coating is selected from the group consisting of a nitride, a carbide, a carbonitride, and an oxide of the group of tantalum, titanium, zirconium, iridium, platinum, and niobium.
- 6. (Original) The electrode of claim 1 wherein the nanotubes are in a form selected from the group consisting of single-wall nanotubes, multi-wall nanotubes, nanotube ropes, carbon whiskers, and combinations thereof.
- 7. (Original) The electrode of claim 1 wherein the nanotubes are of carbon-doped boron nitride.
- 8. (Original) The electrode of claim 1 wherein the nanotubes are characterized as having been grown from a reaction gas selected from the group consisting of acetylene, methyl acetylene-propadiene, and a gas of the paraffin series.
- 9. (Original) The electrode of claim 8 wherein the reaction gas is characterized as having an ammonium addition.
- 10. (Original) The electrode of claim 1 comprising the nanotubes adhering to tantalum coated on a titanium substrate.

- 11. (Currently Amended) A method for providing an implanted implantable electrode inside a body, comprising the steps of:
 - a) providing a substrate;
 - b) coating a catalytic material selected from the group consisting of <u>carbon</u>, nitrogen-doped carbon, tantalum, titanium, zirconium, iridium, platinum, and niobium or a nitride, a carbide, a carbonitride, and an oxide thereof on the substrate;
 - c) heating the coated substrate;
 - d) contacting the heated substrate with a flowing hydrogen-containing gas stream to thereby provide a multiplicity of carbon-containing nanotubes on the coated substrate, the nanotubes comprising a length between first and second ends, wherein a substantial number of the nanotubes are adhered to the substrate at only their first end, and wherein if there are nanotubes adhered to the substrate at both their first and second ends, the first and second ends are of the same polarity; and
 - e) utilizing the nanotube coated substrate as an implantable electrode in direct contact with body fluids or imbedded in body tissue inside the body.
- 12. (Original) The method of claim 11 including heating the coated substrate to a temperature of about 350°C to about 1,150°C.

- 13. (Original) The method of claim 11 including cooling the nanotube coated substrate in hydrogen prior to use.
- 14. (Currently Amended) A method of providing an implantable electrode, comprising the steps of:
 - a) providing a substrate;
 - b) providing nanotubes mixed with a binder precursor selected from chloroiridic acid, chloroplatinic acid, titanium (IV) chloride, zirconium (IV) chloride, niobium (V) chloride, and tantalum (V) chloride in a solvent;
 - c) contacting the binder precursor to the substrate;
 - d) converting the binder precursor to a coating on the substrate having the a multiplicity of nanotubes embedded therein adhered thereto, the nanotubes comprising a length between first and second ends, wherein a substantial number of the nanotubes are adhered to the substrate at only their first end, and wherein if there are nanotubes adhered to the substrate at both their first and second ends, the first and second ends are of the same polarity.
- 15. (Original) The method of claim 14 including heating the binder precursor coated substrate in either an oxidizing or an inert atmosphere.
- 16. (Original) The method of claim 14 including heating the binder precursor coated substrate at a temperature of about 300°C to about 500°C.

- 17. (Original) The method of claim 14 including heating the binder precursor coated substrate for a time ranging from about 30 minutes to about 3 hours.
- 18. (Currently Amended) The method of claim 14 including heating the chloroiridic acid binder precursor in an oxidizing atmosphere to provide the nanotubes embedded in adhered to an iridium oxide binder coated on the substrate.
- 19. (Currently Amended) The method of claim 14 including heating the chloroplatinic acid, titanium (IV) chloride, zirconium (IV) chloride, niobium (V) chloride, and tantalum (V) chloride binder precursors in an inert atmosphere to provide the nanotubes embedded in adhered to a binder of platinum, titanium, zirconium, niobium, and tantalum, respectively, coated on the substrate.
- 20. (Currently Amended) A method for providing an implanted implantable electrode inside a body, comprising the steps of:
 - a) providing a substrate;
 - b) coating a carbonaceous catalytic material on the substrate;
 - c) heating the carbonaceous coated substrate:
 - d) contacting the heated substrate with a flowing hydrogen-containing gas stream to thereby provide a multiplicity of carbon-containing nanotubes on the carbonaceous coated substrate, the nanotubes comprising a length between first and second ends, wherein a substantial number of the nanotubes are adhered to the substrate at only their first end, and wherein if there are

- nanotubes adhered to the substrate at both their first and second ends, the first and second ends are of the same polarity; and
- e) utilizing the nanotube coated substrate as an implantable electrode in direct contact with body fluids or imbedded in body tissue inside the body.
- 21. (Original) The method of claim 20 including heating the carbonaceous coated substrate to a temperature of about 350°C to about 1,150°C.
- 22. (Original) The method of claim 20 including sputtering the carbonaceous catalytic material on the substrate.
- 23. (Original) The method of claim 20 including providing the sputtered carbonaceous catalytic material as nitrogen-doped carbon.
- 24. (Original) The method of claim 20 including providing the nitrogen in the nitrogen-doped carbon at a concentration of about 1 to about 57 atomic percent.

- (Currently Amended) A method for providing an implanted implantable electrode inside a body, comprising the steps of:
 - a) providing a substrate;
 - b) coating a catalytic material selected from the group consisting of carbon, nitrogen-doped carbon, tantalum, titanium, zirconium, iridium, platinum, and niobium or a nitride, a carbide, a carbonitride, and an oxide thereof on the substrate;
 - subjecting the coated substrate to a plasma c) assisted chemical vapor deposition process containing a flowing hydrocarbon-containing gas stream to thereby provide a multiplicity of carbon-containing nanotubes on the coated substrate, the nanotubes comprising a length between first and second ends, wherein a substantial number of the nanotubes are adhered to the substrate at only their first end, and wherein if there are nanotubes adhered to the substrate at both their first and second ends, the first and second ends are of the same polarity; and
 - d) utilizing the nanotube coated substrate as an implantable electrode in direct contact with body fluids or imbedded in body tissue inside the body.
- 26. (Original) The method of claim 25 including utilizing microwave excitation in the plasma assisted chemical vapor deposition process.